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layering a second conductive material over said first conductive material.

Sub D2
44. (Amended) The method in claim 43, wherein said step of releasing nitrogen from said plasma with electromagnetic energy comprises directing ultraviolet light toward said gas.

Sub D3
76. (Amended) A method of passivating a multilayer conductive structure, comprising:

layering a first conductive material;
introducing N_2 plasma to said first conductive material;
releasing nitrogen from said plasma with electromagnetic energy;

and

layering a second conductive material over said first conductive material.

77. (Amended) A method of passivating a multilayer conductive structure, comprising:

layering a first conductive material;
introducing NH_3 plasma to said first conductive material;
releasing nitrogen from said plasma with electromagnetic energy;

and

layering a second conductive material over said first conductive material.